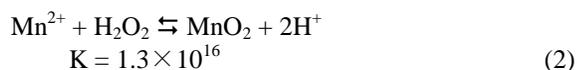
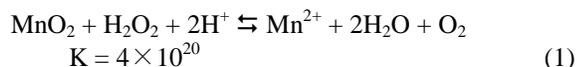


A self-healing phenomenon of thin δ -MnO₂ film in the oxidative decomposition of hydrogen peroxide

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Everybody knows the fact that bulk MnO₂ catalyzes oxidative decomposition of aqueous H₂O₂. Its mechanism can be described as follows, according to the literature [1]:



It should be noted that the catalytic cycle is maintained only when sufficient amounts of MnO₂ and H₂O₂ are involved. In other words, it is difficult to remove a small amount of H₂O₂ completely using a thin film of MnO₂, avoiding its leaching. In this work, we have focused on the leaching of δ -MnO₂ film during oxidative decomposition of H₂O₂. When a constant potential of +0.8 V was applied, a self-healing phenomenon of the film was found as a result; that is, the δ -MnO₂ film reacts with H₂O₂ to be reduced to soluble Mn²⁺ ions which are oxidized at +0.8 V, returning to MnO₂ film where the reaction with H₂O₂ is resumed.

An aqueous solution of 2 mM KMnO₄ was used as the deposition bath. A constant potential of 0 V vs Ag/AgCl was applied to an ITO glass electrode to deposit thin film of MnO₂. In this condition, low-crystalline birnessite (δ -MnO₂) can be created [2]. The ITO-supported MnO₂ film was immersed into a 0.5 M Na₂SO₄ solution containing 2 mM H₂O₂ and held at open-circuit potential (+0.15), +0.4, +0.6, +0.8, and +1.0 V. A glassy carbon disk, which is inactive toward H₂O₂, was used as the counter electrode. Concentration of residual H₂O₂ was evaluated as a function of time according to the phenolphthalin method. On the other hand, *in situ* UV-vis spectra were acquired in a quartz cuvette filled with the same solution. The MnO₂/ITO working electrode was located perpendicular to the light beam while small counter and reference electrodes were placed outside of the beam.

Figure 1 shows time course of absorption spectra due to phenolphthalein (red) which had been generated by the oxidation of phenolphthalein (colorless) with H₂O₂, taken at an applied potential of +0.8 V. The absorbance at $\lambda = 552$ nm was depicted in the inset, which was normalized to the initial value. Concentration of residual H₂O₂ (A/A_0) decreased immediately after immersion and reached nearly 0 in 24 h, meaning the complete loss. One should note the slowing down of the absorbance decrease in the region from 90 to 400 min. *In situ* absorption spectra of the MnO₂ film on an ITO substrate were recorded under the same conditions as the above. Broad absorption with no distinct peaks appear between 300 and 700 nm, which can be ascribed to $d-d^*$ transition of the Mn⁴⁺ state ($t_{2g}^3 e_g^0$). The inset indicates the time course of the normalized absorbance (A/A_0) at 380 nm. The absorption decreased in intensity immediately after starting the measurement, due to the leaching of MnO₂

film as a result of the reduction to soluble Mn²⁺ with H₂O₂. Interestingly, the absorbance increased from 90 min to reach almost its original value. As shown in Figure 3, the film obtained after polarization at +0.8 V with H₂O₂ exhibited more intense diffraction peak at 12° in 2θ than the as-deposited film. Since this peak can be assigned to δ -MnO₂, it is reasonable to assume that Mn²⁺ ions generated as a result of the reaction between MnO₂ and H₂O₂ are oxidized at +0.8 V in the presence of Na⁺ ions, depositing again on the surface of ITO electrode with the same crystalline structure. At an applied potential of +0.9 V, the MnO₂ film remained unchanged during the reaction with H₂O₂, while H₂O₂ was decomposed completely. Here, the generated Mn²⁺ ions can be rapidly reoxidized before leaching.

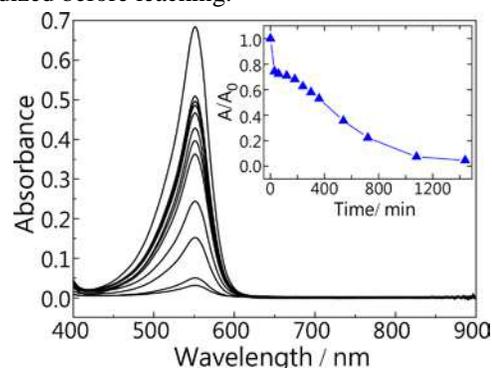


Fig. 1 Time course of absorption spectra taken by the phenolphthalin method to determine the residual amount of H₂O₂. Polarization was made at +0.8 V in a 0.5 M Na₂SO₄ solution with 2 mM H₂O₂.

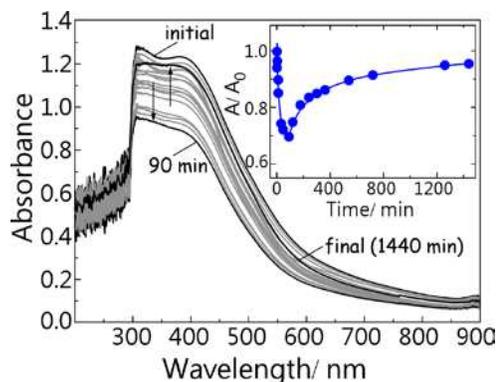


Fig. 2 *In situ* absorption spectra of δ -MnO₂ film obtained in a 0.5 M Na₂SO₄ solution with 2 mM H₂O₂ at an applied potential of +0.8 V.

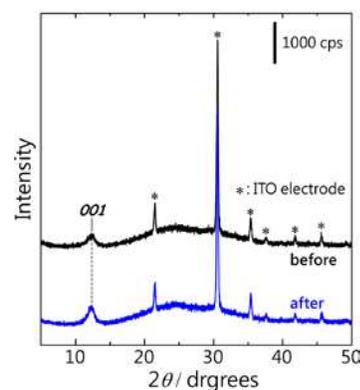


Fig. 3 XRD patterns of the δ -MnO₂ film before and after polarization at +0.8 V in a 0.5 M Na₂SO₄ solution with 2 mM H₂O₂.

References

- [1] Broughton and Wentworth, *J. Am. Chem. Soc.*, **69**, 741 (1947).
- [2] Nakayama *et al.*, *J. Electrochem. Soc.* **159**, A1176 (2012).